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Correction: A generalized method for alignment of block copolymer films: solvent vapor annealing with soft shear

Zhe Qiang,^a Yuanzhong Zhang,^a Jesse A. Groff,^b Kevin A. Cavicchi*^a and Bryan D. Vogt*^a

Correction for 'A generalized method for alignment of block copolymer films: solvent vapor annealing with soft shear' by Zhe Qiang *et al.*, *Soft Matter*, 2014, **10**, 6068–6076, <https://doi.org/10.1039/C4SM00875H>.

The authors regret that on page 6070 in the section labelled "Characterization" an incorrect version of an equation was shown. The equation originally read " $S = L/L_0$ ". This equation should be " $S = (L - L_0)/L_0$ ".

For the work presented in this paper, the correct expressions were used in the calculations. Hence, this correction has no influence on the results and conclusions of the paper.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

^a Department of Polymer Engineering, University of Akron, Akron, OH 44325, USA. E-mail: vogt@uakron.edu, kac58@uakron.edu

^b Marlinton High School, 10450 Moulin Ave NE, Alliance, OH 44601, USA

